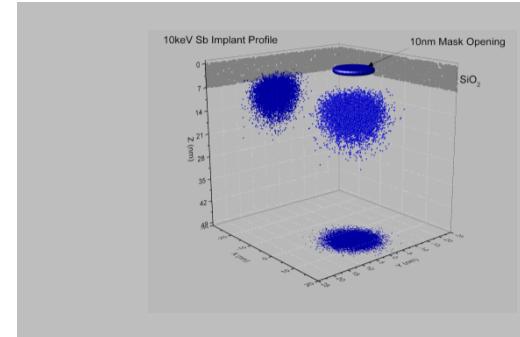
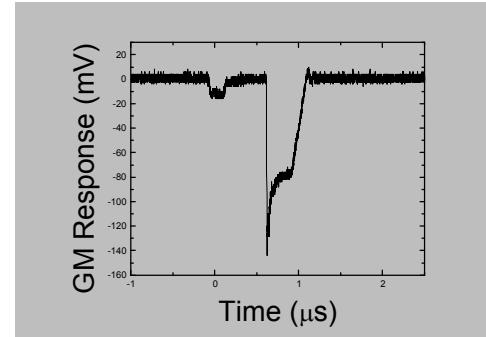
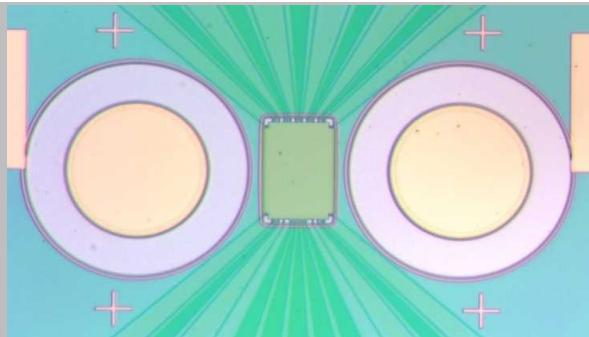


Exceptional service in the national interest



Optimization of avalanche photodiodes for the detection of subsurface single ion implants in Silicon

J. Abraham, P. A. Sharma, J. L. Pacheco,
E. Bielejec and M. S. Carroll

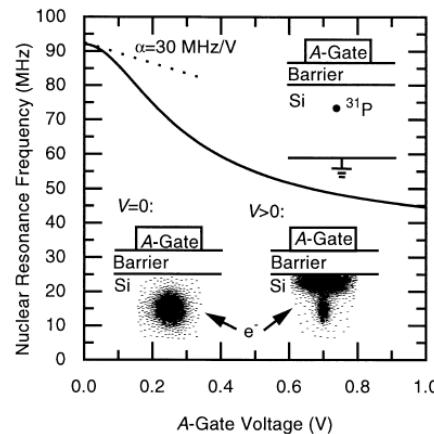
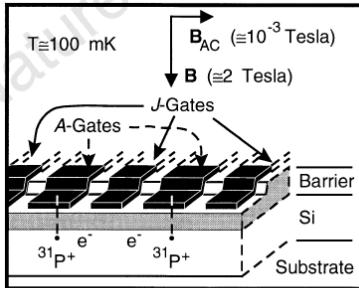


Sandia National Laboratories is a multi-program laboratory managed and operated by Sandia Corporation, a wholly owned subsidiary of Lockheed Martin Corporation, for the U.S. Department of Energy's National Nuclear Security Administration under contract DE-AC04-94AL85000. SAND NO. 2011-XXXX

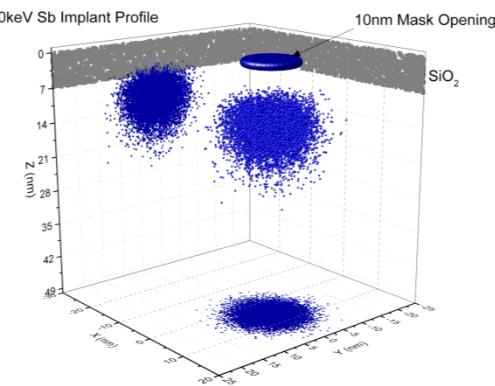
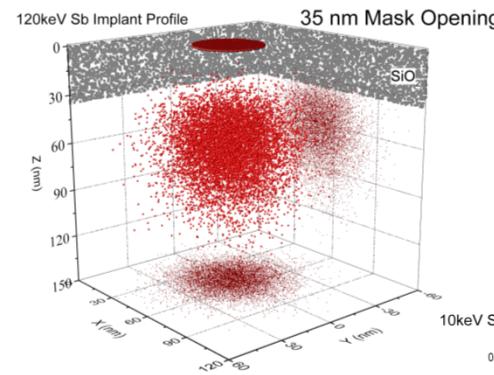
Outline

- Deterministic Implants for Quantum devices
- Avalanche Photodiode (APD)
Design, Performance and Characterization
- Laser Testing
- Conclusion/Outlook

Deterministic Implantation

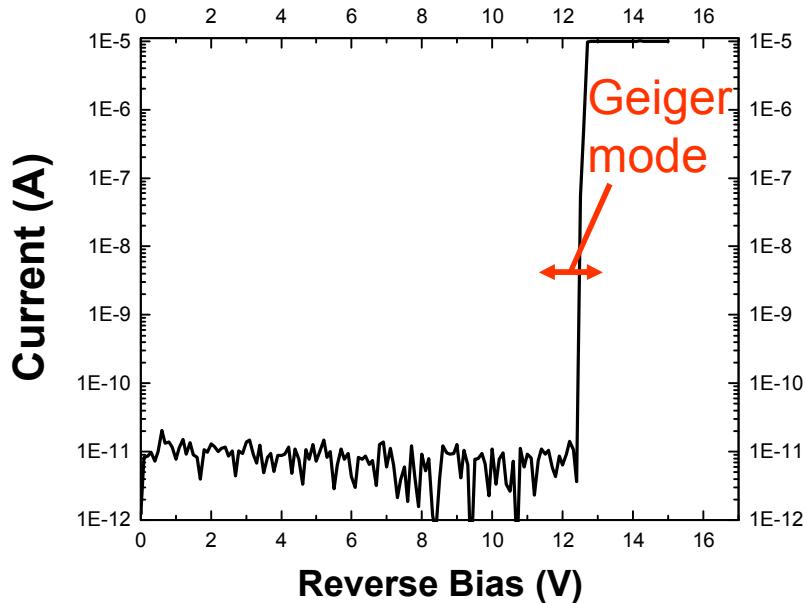
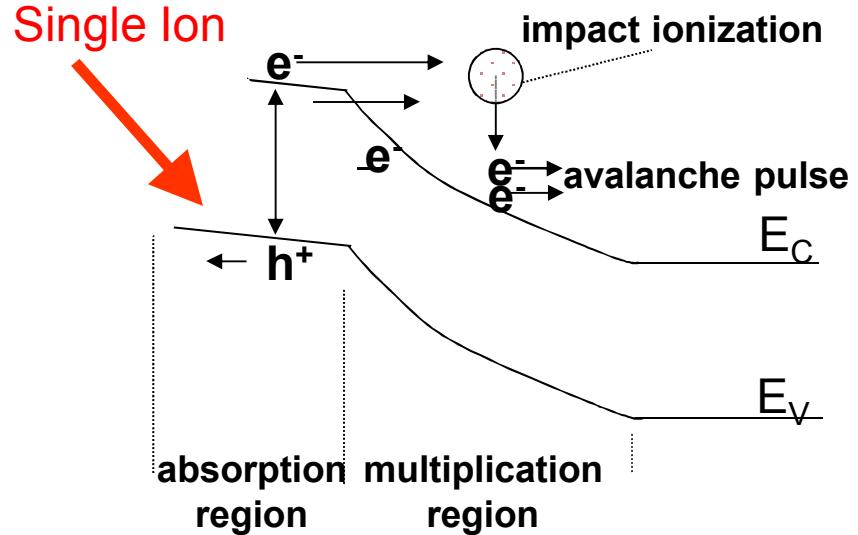


B. E. Kane, Nature 393, 1998



- Coupling to an electron?
- Deterministic implants for quantum devices – to overcome the limitation of Poisson Statistics
- Monte Carlo simulation illustrates the challenge of straggling

APD Introduction

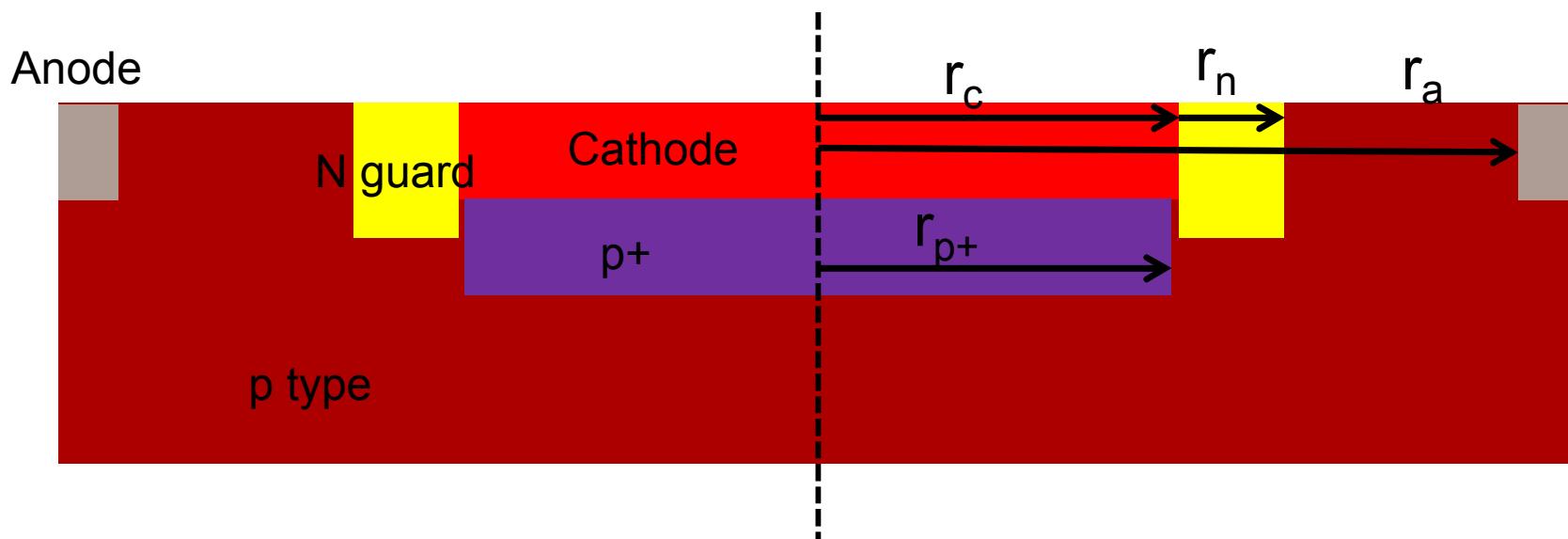


- Reverse bias pn junction
- APD produces internal gain due to high field impact ionization (sensitive to local doping profile)

Geiger Mode Operation

- Pulse bias above breakdown
- Geiger-mode: gated device
- Gain meaningless (digital signal)

APD Geometry

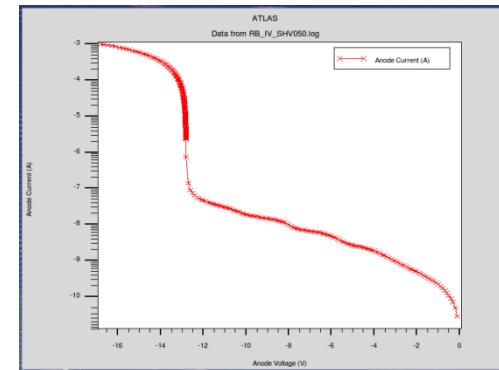
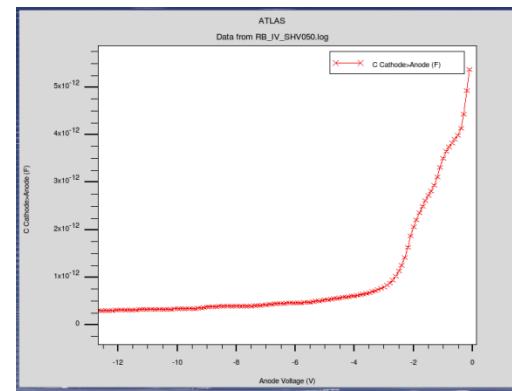
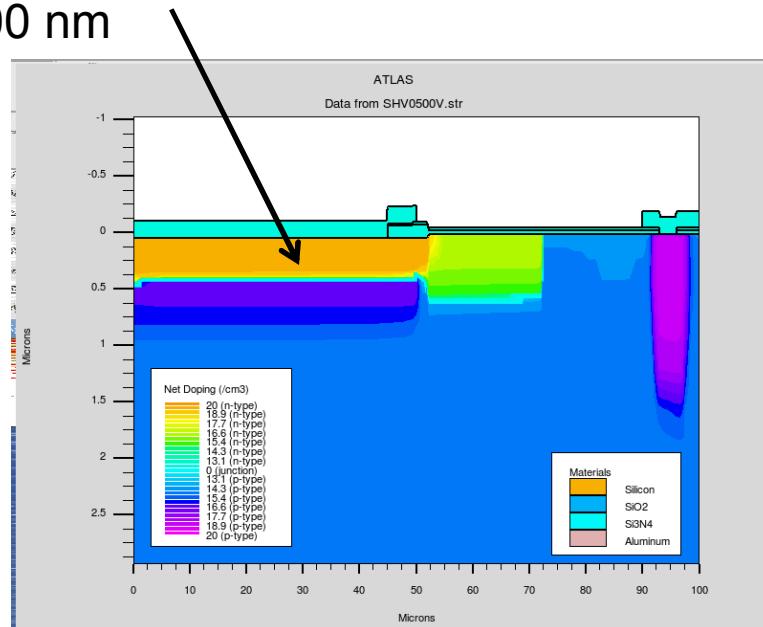


- Schematic of the device design
- Experiments varying r_{p+} , r_a , r_n/r_c are performed to understand how to optimize eh pair detection for detection in the guard ring vicinity.

APD modeling with TCAD

Junction depth:

400 nm

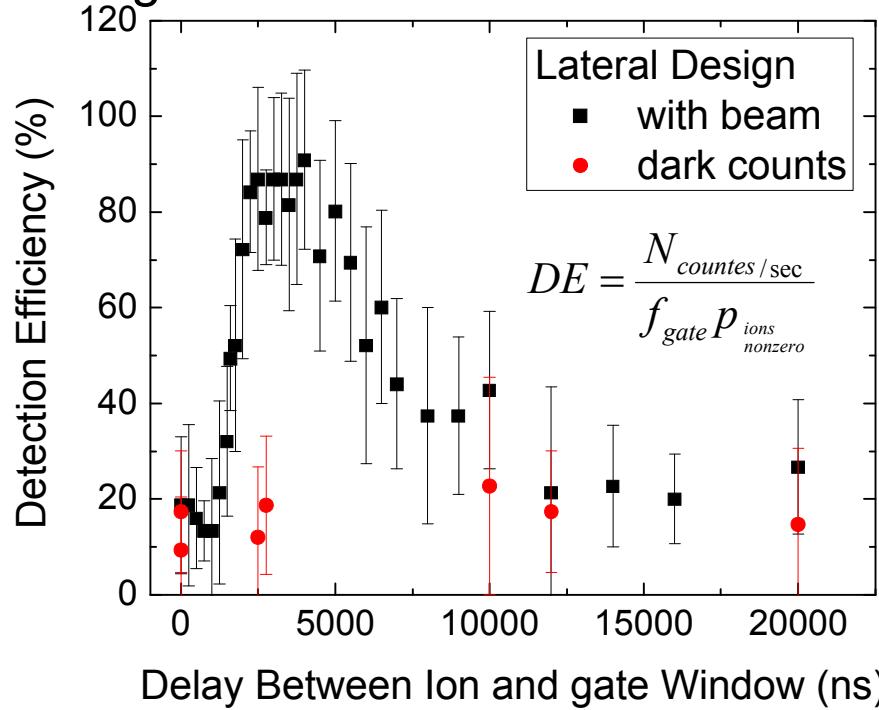


TCAD Modeling for junction depth characterization in order to understand the length scales and sensitive volumes of the device.

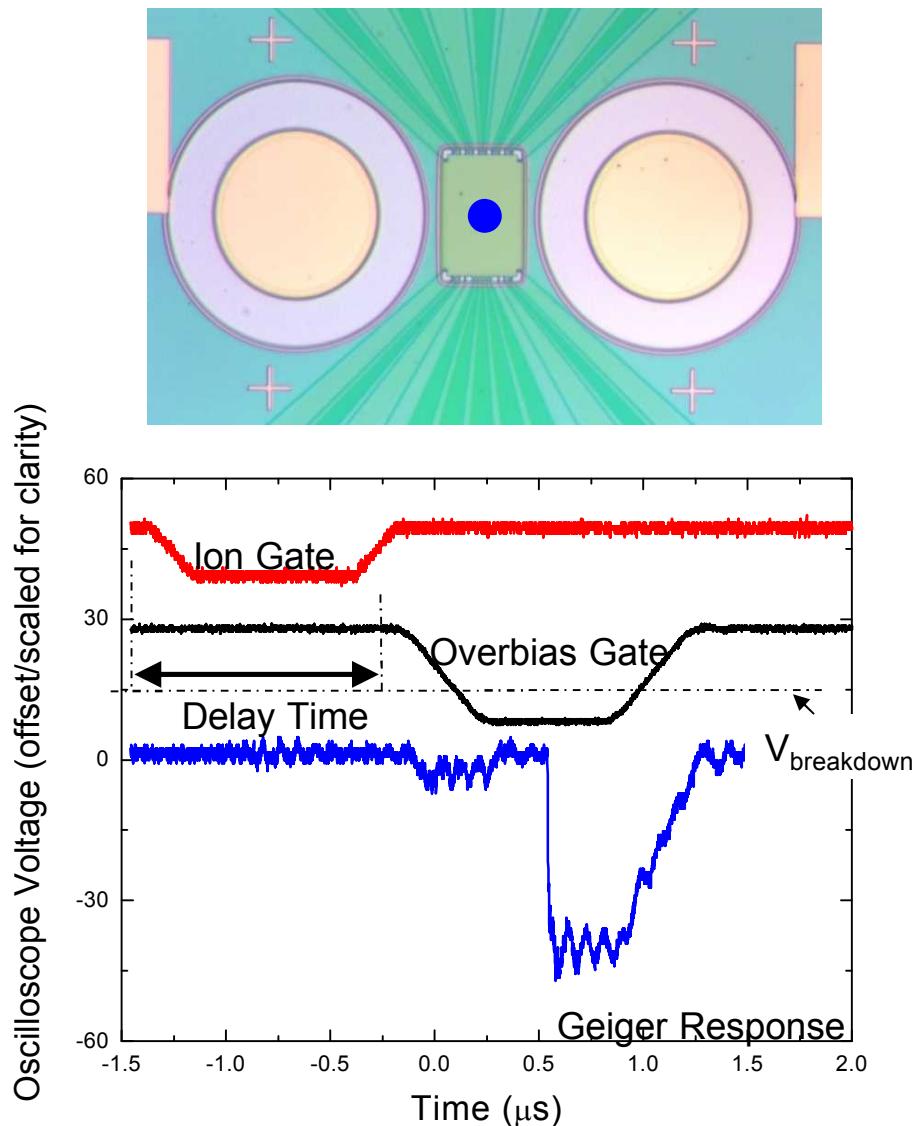
Fidelity check with IV and CV characterization

APD Ion Response

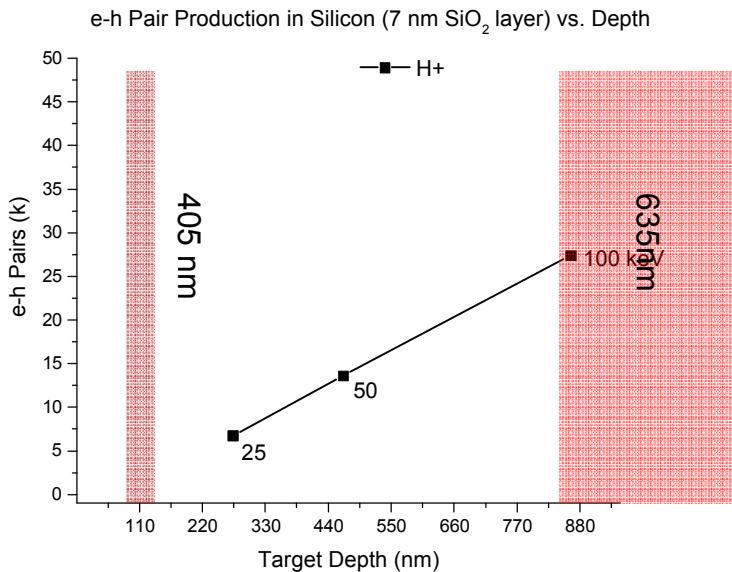
Ion Irradiation with 120 keV H⁺ at ~1 ions/gate



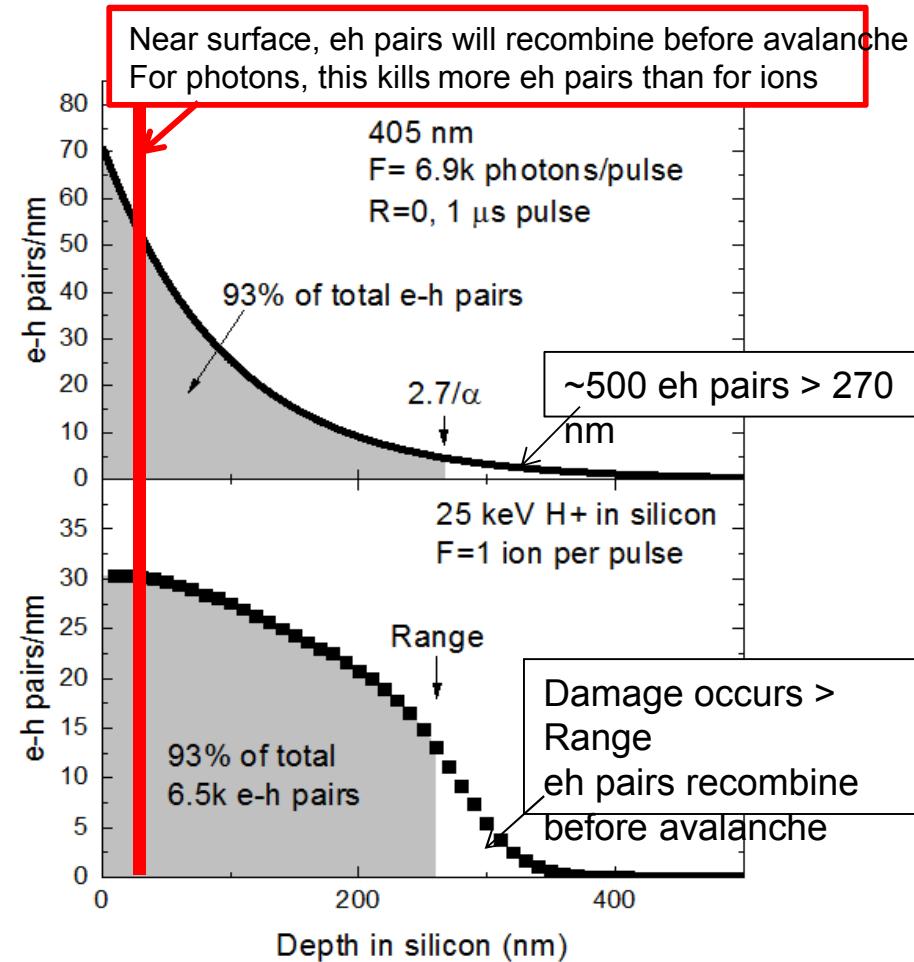
Detect single ions with detection efficiency approaching ~100% for diffused carriers



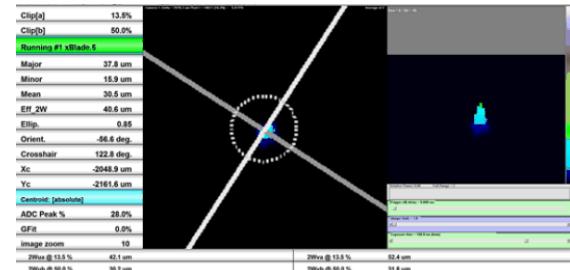
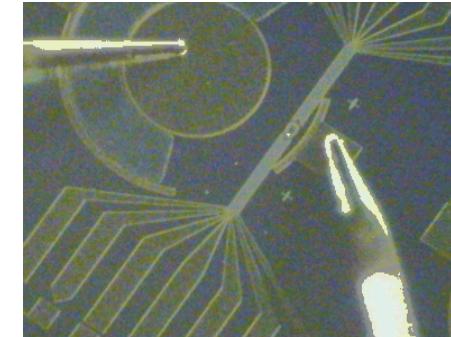
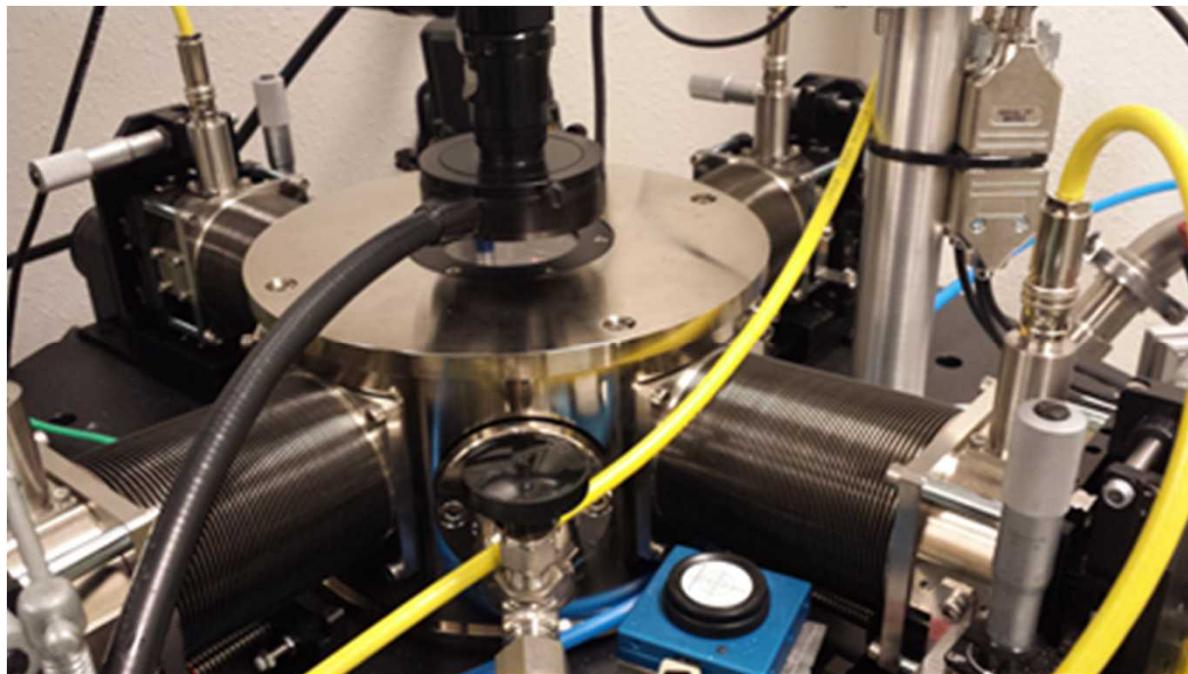
Ion vs. Photon Response



Use photon response to characterize
Bound ion response response.



Testing Chamber



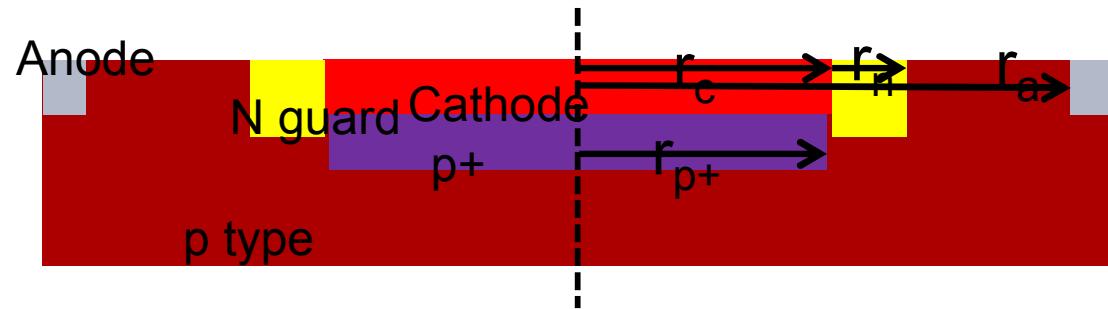
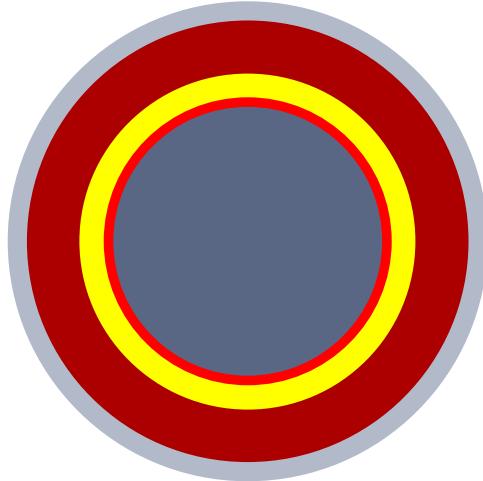
Laser/Microscope/CCD Column

XYZ stage

4 point probe station

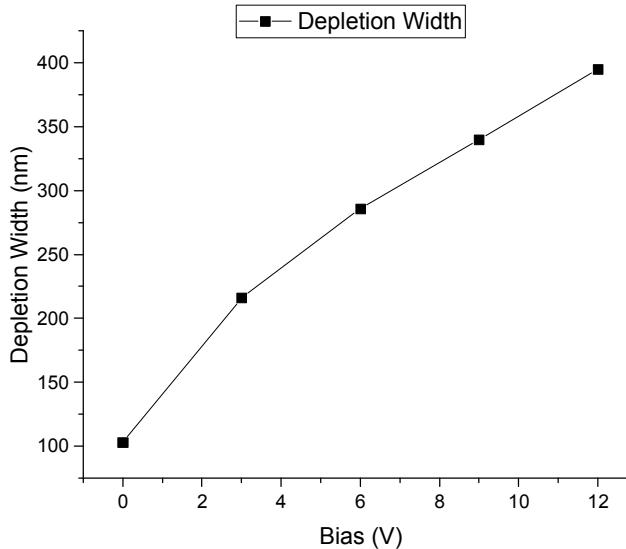
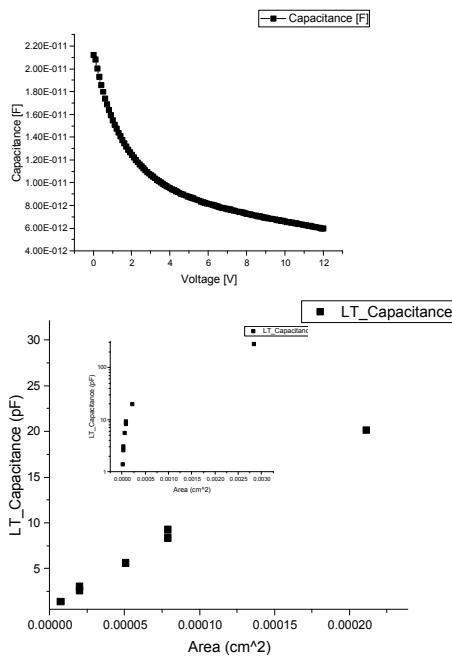
Can cool device – work at 77 K

Experimental Scheme



- Three Experimental Arms:
 - Anode radius
 - P+ radius
 - N guard radius

CV measurements



- All devices fit on curve of C versus Area of Cathode/p+ junction
- Can extract depletion width from CV data

Detection Efficiency



Device is gated with GM pulse

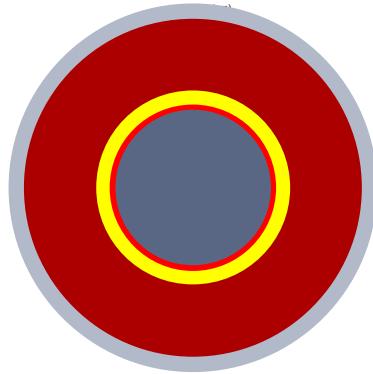
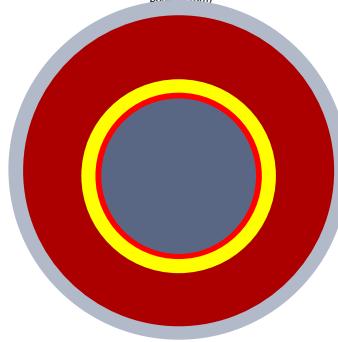
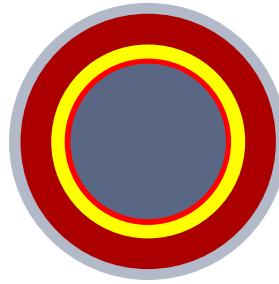
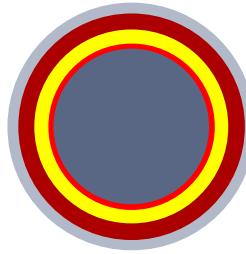
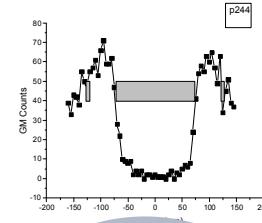
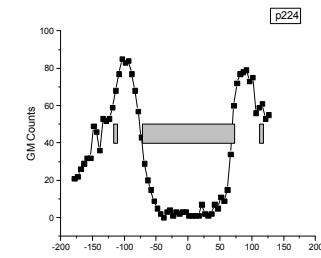
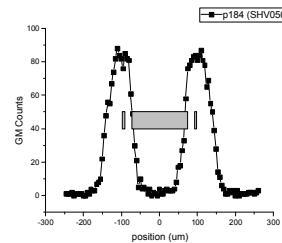
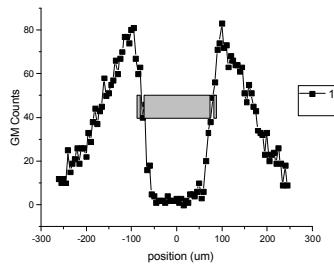
Laser illuminates device

SR400 photon counter detects pulses above threshold

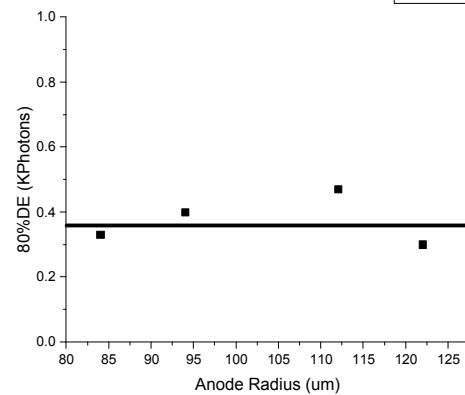
Experiment is repeated at 100 Hz.

80%DE -> 80 pulses above threshold for 100 experiments

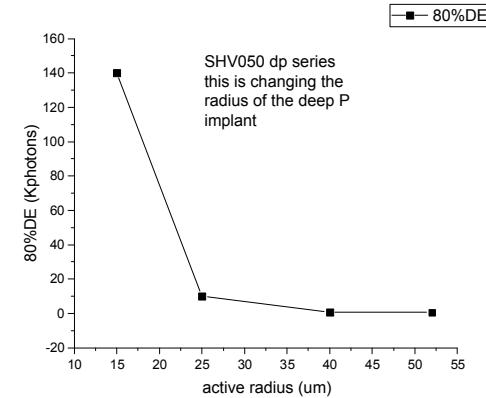
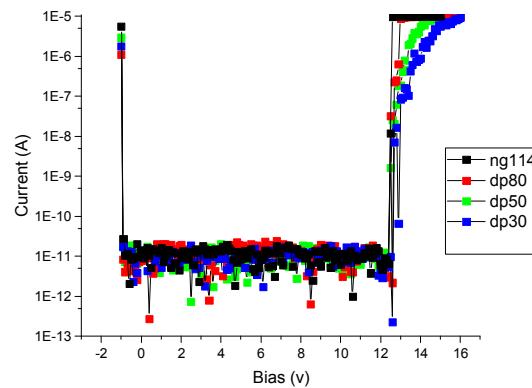
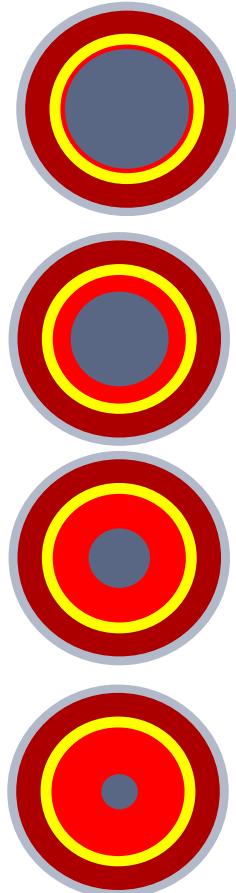
Anode Series



- Anode position is not a significant factor for DE
- Thermal velocity \gg drift velocity, expect diffusion length to dominate

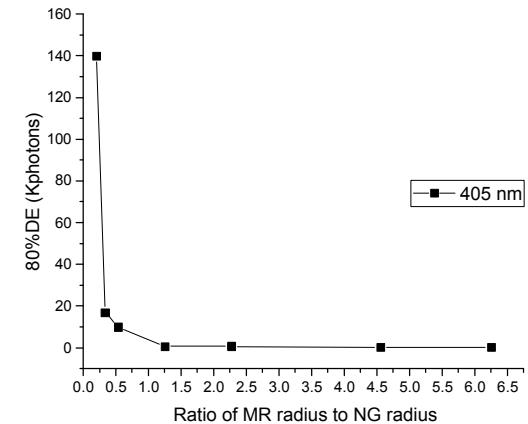
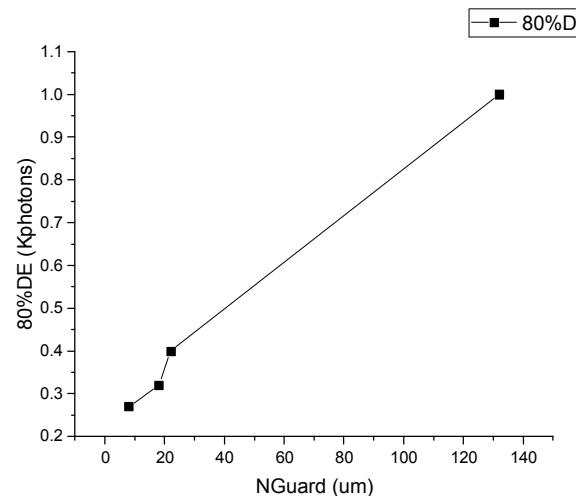
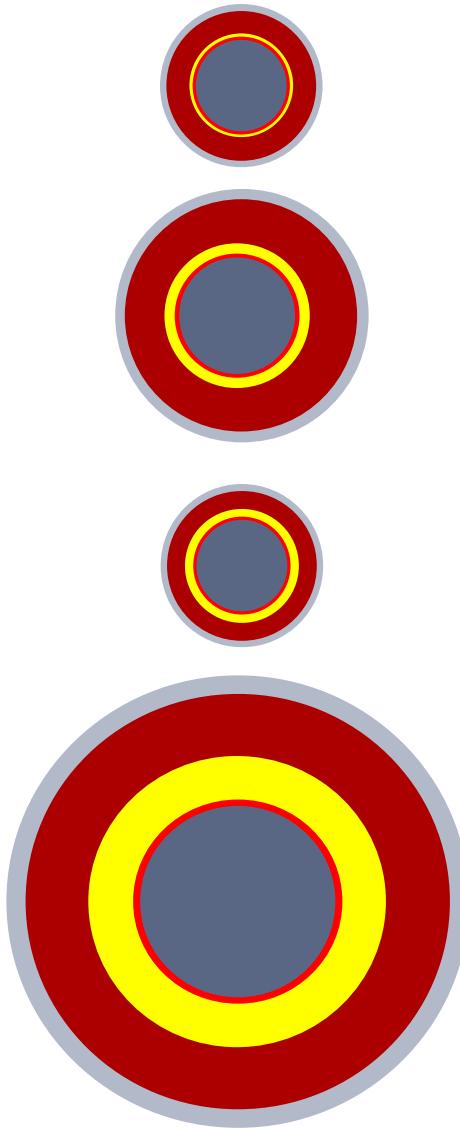


p+ Series (IV measurements)



- Larger active radius improves Sensitivity- to a point – it improves the leak E field value in the multiplication region -> improving the probability of impact ionization

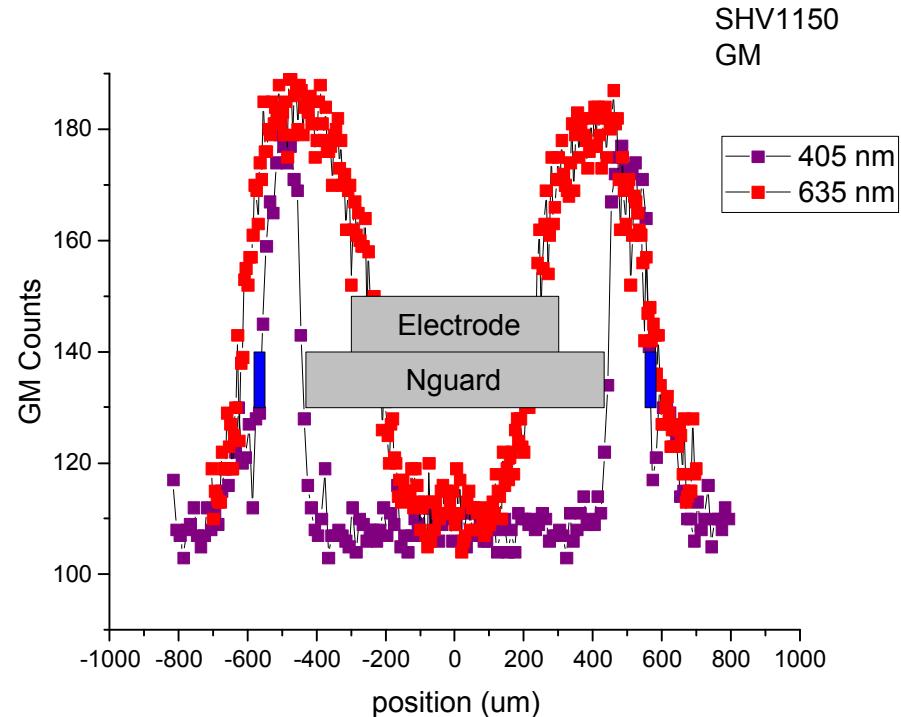
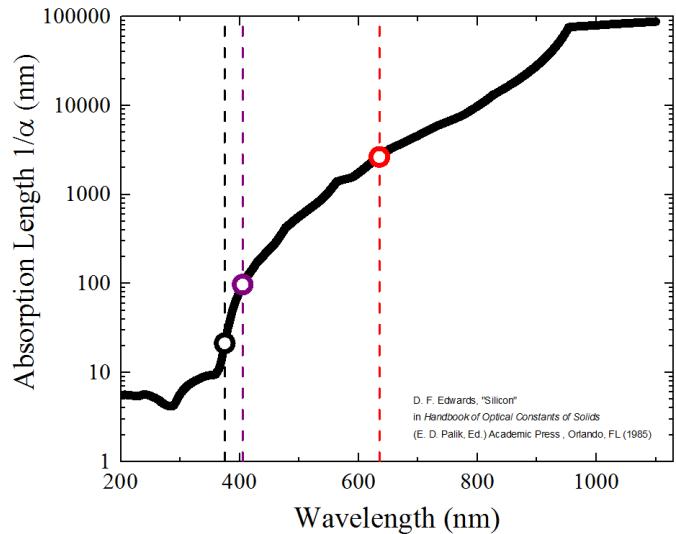
SHV Series (nguard issue)



- Larger guard ring is an issue for DE
- Can combine the results from the SHV series and guard ring series

635 nm Confirmation

$$\text{GR}(z) = F(1 - R)\alpha e^{-\alpha z}$$



- For 405 need to keep a large MR to Nguard ratio.
- Diffusion dominates the collection, we are far from the junction – (need to compare thermal velocity to the field – drift velocity) so the N-guard pushes us further from the multiplication region.

Conclusion/Outlook



- Laser testing can provide insight to APD performance with Ion detection
- The Guard ring looks to be problematic for shallower implants
 - UV tests will confirm
 - A device redesign may be required for subsurface detection